ZnO/SiO₂ core/shell nanowires for capturing CpG rich single-stranded DNAs†

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Atomic layer deposition (ALD) is capable of providing an ultrathin layer on high-aspect ratio structures with good conformity and tunable film properties. In this research, we modified the surface of ZnO nanowires through ALD for the fabrication of a ZnO/SiO₂ (core/shell) nanowire microfluidic device which we utilized for the capture of CpG-rich single-stranded DNAs (ssDNAs). Structural changes of the nanowires while varying the number of ALD cycles were evaluated by statistical analysis and their relationship with the capture efficiency was investigated. We hypothesized that finding the optimum number of ALD cycles would be crucial to ensure adequate coating for successful tuning to the desired surface properties, besides promoting a sufficient trapping region with optimal spacing size for capturing the ssDNAs as the biomolecules traverse through the dispersed nanowires. Using the optimal condition, we achieved high capture efficiency of ssDNAs (86.7%) which showed good potential to be further extended for the analysis of CpG sites in cancer-related genes. This finding is beneficial to the future design of core/shell nanowires for capturing ssDNAs in biomedical applications.

Introduction

Extraordinary properties of nanostructured materials have led to their evolution as zero-dimensional nanoparticles,1,2 one-dimensional nanotubes and nanowires,3,4 two-dimensional nanosheets5 and nanoplates,6 and three-dimensional nanoballs7 and nanoflowers.8 Among these nanomaterials, nanowires have shown good potential in various applications due to their exceptionally high surface-to-volume ratio and strong structure.9,10 Owing to these advantages, their applications have been broadened to include the recognition of biomolecules11–15 and aptamer-incorporated nanowires based on single-stranded DNAs (ssDNAs) or RNA oligonucleotides have received considerable interest in biosensing,16–18 disease diagnoses19,20 and drug deliveries.21–23 Among the materials studied, ZnO nanowires grown by a hydrothermal method have been widely used due to their several advantages which include low fabrication cost, low temperature-driven growth, high fabrication yield34,35 and feasibility for tuning structural properties of the nanowires; hence ZnO nanowires have the promise of applications in diverse fields.25–27 However, some researchers reported a toxicity risk when using ZnO based materials;28–31 and hence, surface coating on ZnO nanowires, especially by the widely used silicon dioxide (SiO₂),32,33 has become a countermeasure to prevent dissolution of Zn²⁺. SiO₂ based materials have been widely used in solid-phase extraction of nucleic acids,34,35 a common method for the adsorption, purification and isolation of nucleic acids which relies on a reversible interaction between the nucleic acids and the solid support. Hence we chose to fabricate ZnO/SiO₂ (core/shell) nanowires for capturing ssDNAs.

For fabrication of the ZnO/SiO₂ (core/shell) nanowires, ZnO nanowires were grown through a hydrothermal method followed by surface modification through atomic layer deposition (ALD). ALD is a robust vapor phase method based on sequential, self-limiting reactions enabling the formation of ultrathin layer films with precise thickness and good uniformity.36 Although ALD is a powerful technique for achieving coating thicknesses at the nanometer level, it is crucial to ensure conformal coating of the whole nanowire framework as the conformal coating determines the success of tuning to the desired surface.
properties.\textsuperscript{37,38} We furthered our investigation by varying the number of ALD cycles to 10, 25, 55, 100 and 200 cycles which is expected to cause remarkable changes to the structure of the nanowire framework due to the increase in coating thickness, and finally, to influence the capture efficiency of ssDNAs.

The ZnO/SiO\textsubscript{2} nanowires were embedded in a microchip device that was integrated with a syringe pump system and applied for capturing CpG rich ssDNAs. The uncaptured ssDNAs were collected in a centrifugation tube and then quantified using qPCR. ssDNAs with the CpG rich sequence have become a binding material of interest especially for aptamers which can be further extended as capture probes for the recognition of DNA methylation on CpG sites, a widely known biomarker in cancer-related genes.\textsuperscript{39,40} As capturing occurs while the ssDNAs traverse through the nanowire arrays under an applied flow rate, there should be a suitable nanowire spacing in the trapping region to capture them. Although the dispersely distributed nanowires are foreseen as a good platform for the trapping region, we supposed that for capturing small biomolecules such as ssDNAs, there should be an optimum spacing between the nanowires to achieve maximum capture efficiency.

Methodology

**PDMS microchannel mold fabrication**

The mold for fabricating a polydimethylsiloxane (PDMS) microchannel was formed on a 3-inch N-type <100> silicon wafer (Advantech Co., Ltd., Japan). The silicon wafer was spin-coated with 3 mL SU-8 3005 (Nippon Kayaku., Ltd., Japan), baked at 95 °C for 3 min and then subjected to photolithography with UV energy of 200 mJ cm\textsuperscript{2} for two microchannel patterns formation on one silicon wafer. This was followed by post-baking at 65 °C and 95 °C for 1 min and 2 min, respectively. Next, the patterns were developed using SU-8 developer (Nippon Kayaku Co., Inc.), rinsed with isopropyl alcohol (IPA) (Kanto Chemical Co., Inc., Japan) and by silanization treatment with trichloro(1H,1H,2H,2H-perfluorooctyl)silane (Merck KGaA, Germany) for 2 h. The resulting silicon wafer which had two photolithographed-SU-8 microchannel patterns with dimensions of 10 mm length, 5 mm width and 10 \( \mu \)m height was later used as a mold for the PDMS microchannel. A mixture of Silpot184 (Dow Corning Toray Co., Ltd.) and curing agent Catalyst Silpot184 (Dow Corning Toray Co., Ltd.) at a ratio of 10 : 1 was poured into the mold, a vacuum pressure was applied to remove air bubbles and the mold was heated at 80 °C for 2 h. After peeling off the PDMS microchannel, the inlet and outlet holes were then made using a 0.5 mm hole puncher (Harris Uni-Core, USA).

**Zinc oxide nanowire microfluidic device fabrication**

Fig. 1a illustrates the steps (i) to (x) for the nanowire microfluidic device fabrication process. A pre-cleaned fused silica substrate with 20 mm \( \times \) 20 mm \( \times \) 0.5 mm dimensions (Crystal Base Co., Ltd., Japan) (step i of Fig. 1a) was spin-coated with...
1,1,3,3,3-hexamethyldisilazane (OAP, Tokyo Ohka Kogyo Co., Ltd., Japan) and then with OFPR8600 (Tokyo Ohka Kogyo Co., Ltd.) (steps ii and iii, respectively). Next (step iv), photolithography was performed to make two areas for the nanowire growth which each had a length of 10 mm and width of 5 mm. The pattern areas were developed using NMD-3 solution (Tokyo Ohka Kogyo Co., Ltd.). An RF-sputtering machine (SVC-700RF I, Sanyu Electron Co., Ltd., Japan) was utilized to sputter a seed layer of ZnO (thickness, 130 nm) on the substrate for 10 min (step v). Hydrothermal growth of ZnO nanowires was performed by immersing the substrate into a mixture of 40 mM hexamethylenetetramine (HMTA, Wako Pure Chemical Industries, Ltd., Japan) and 40 mM zinc nitrate hexahydrate (Thermo Fisher Scientific Inc.) followed by heating at 95 °C for 3 h (step vi). The OFPR8600 was then removed using acetone (Kanto Chemical Co., Inc.) leaving the nanowires on the desired areas (step vii).

After fabrication of ZnO nanowires, an ALD system (Savannah G2, Ultratech Inc., USA) was used to deposit a thin layer of SiO2 to fabricate core/shell nanowires (Fig. 1a, step viii). The conditions used were: precursors, tris(dimethylamino)silane (TMAS) and ozone; temperature, 150 °C; number of ALD cycles, 10, 25, 55, 100 and 200. The resulting fused silica substrate with nanowires was then attached with the PDMS microchannel (step ix). The surfaces of the PDMS and the nanowire-grown substrate were first treated using a plasma etching apparatus (Meiwafosis Co., Ltd., Japan) and then heated at 180 °C for 2 min to assist the bonding process. A 0.5 mm diameter polyetheretherketone (PEEK) tube (Institute of Microchemical Technology Co., Ltd., Japan) was then inserted into the inlet hole and into the outlet hole (Fig. 1a, step x).

FESEM and STEM-EDS characterization of nanowires
A field emission scanning electron microscope (FESEM) (SUPRA 40VP Carl Zeiss, Germany) was utilized to characterize the surface morphology of the nanowires. Elemental mappings of the ZnO/SiO2 core/shell nanowires were obtained using a scanning transmission electron microscope (JSM-7610F, JEOL, Japan) equipped with an energy dispersive X-ray spectrometer (STEM-EDS) operated at an acceleration voltage of 30 kV. The images were obtained with 512 × 384 pixels at a scan rate of 0.1 ms and they were integrated for 100 cycles. The peaks of Zn Kβ (8.630 keV), O Kα (0.525 keV), and Si Kα (1.739 keV) were used to construct the images (ESI Fig. 1†). The statistical analysis of the coating thickness, diameter, length, aspect ratio and spacing between nanowires was performed with an image processing program, Image J using the images from FESEM and STEM-EDS. Because of the dispersed distribution of nanowires, spacings between them were measured at a low height (evaluation at 700 nm from the nanowire bottom) and at an upper region (evaluation at 700 nm from the nanowire top).

Zeta potential measurement
The zeta potential of 50 ng mL⁻¹ DNA in Millipore water solution was measured at 25 °C using a dynamic-light scattering spectrophotometer (ZETASIZER Nano-ZS Malvern Panalytical, UK). ZnO/SiO2 nanowires were fabricated on a glass substrate (26 mm wide × 37 mm long × 1.0 mm thickness) followed by zeta potential measurement (ELSZ-2000, Otsuka Electronics, Japan) in Millipore water at 25 °C.

Capture experiment of ssDNA using the nanowire microfluidic device
The ssDNAs, primers and probes used in this experiment were obtained from Invitrogen, Thermo Fisher Scientific, Inc.; their sequences were: (i) ssDNA, 5'-ATACCGCGTACTGCCTGACG-3'; (ii) forward primer, 5'-AGCGCGTACTGCCTGACG-3'; (iii) reverse primer, 5'-GGTACCGCGACG-3'; and (iv) probe, 5'-FAM-ATCGCGTCCTCGCGCTGACC-3'. 50 ng mL⁻¹ of DNA was prepared by dissolving the stock DNA in Millipore water. The capture experiment was performed using a syringe pump system (KDS-200, KD Scientific Inc., USA) at a flow rate of 5 μL min⁻¹. 50 μL of Millipore water was introduced prior to sample introduction to remove any possible contaminates. Then, 50 μL of 50 ng mL⁻¹ DNA was introduced into the inlet of the microfluidic device and the recovered amount was collected in a 1 mL centrifuge tube.

Quantifications of DNA
The recovered ssDNAs were analyzed using a PIKOREAL 96 real-time polymerase chain reaction (RT-PCR) system (Thermo Fisher Scientific Inc.). A mixture containing 1 μL DNA solution, 3.5 μL Millipore water, 5 μL TaqMan® Gene Expression Master Mix (Applied Biosystems, Thermo Fisher Scientific Inc., USA) and 0.5 μL of the Custom TaqMan® Gene Expression Assays (Applied Biosystems, Thermo Fisher Scientific Inc.) was pipetted into a 96-well reaction plate, sealed with an optical seal (Applied Biosystems, Thermo Fisher Scientific) and RT-PCR was run. The protocol for RT-PCR was carried out using the cycling conditions 2 min at 50 °C, 10 min at 95 °C, 50 cycles of 15 s at 95 °C and 1 min at 60 °C. The amount of captured DNA was calculated by deducting the amount of recovery from the input DNA.

Results and discussion
Surface modification using ALD
Surface modification of the nanowire through ALD for the fabrication of core/shell nanowires has been proven able to improve surface adsorption of target molecules. In the present research, we grew ZnO nanowires by a hydrothermal method followed by surface modification using ALD to fabricate the ZnO/SiO2 (core/shell) nanowires. Fig. 1b schematically showed details for fabrication of the core/shell nanowires using ALD. The reactant and co-reactant used were tris(dimethylamino)silane (TMAS) and ozone (O3), respectively. The process was initiated with the exposure of the first reactant to hydroxylated ZnO nanowires followed by nitrogen (N2) purging to remove the unreacted chemical species. The next reaction involved the introduction of co-reactant as the oxygen source followed by N2 purging which resulted in monolayer formation.
The sequence was repeated for the following numbers of ALD cycles: 10, 25, 55, 100 and 200 to yield nanowires with different coating thicknesses (Fig. 1c). The sequential deposition of the reactant and co-reactant led to the ultrathin film with good conformality.

**Characterizations and statistical analysis of ZnO/SiO₂ while varying number of ALD cycles**

STEM-EDS was utilized to obtain a more detailed analysis for the composition of ZnO/SiO₂ nanowires. Successful formation of a very thin SiO₂ film can be observed starting from 10 cycles followed by increment in film thickness as the number of ALD cycles further increased until 200 cycles were reached (Fig. 2a and ESI figure†). The resulting SiO₂ thickness had a linear relationship with the number of ALD cycles with an approximate growth rate of 0.13 nm per cycle (Fig. 2b). Surface morphology of the nanowires was characterized using FESEM which indicated an increase in the size of nanowires with increasing number of ALD cycles (Fig. 2c).

The dependence of nanowire structural properties on number of ALD cycles was investigated by statistical analysis of important parameters which include the diameter, length, aspect ratio and spacing between nanowires. Fig. 3a summarizes the size distribution of bare ZnO nanowires and the maximum peak was for the diameter range of 60–90 nm and for the length range of 1.6–1.8 μm. A consistent increase in the diameter and length of the nanowires could be observed with increasing number of ALD cycles suggesting uniform deposition of SiO₂ film was provided by ALD (Fig. 3b). Aspect ratios, in the range of 15 to 19, were decreasing as the number of ALD cycles increased in Fig. 3c. Due to the dispersed distribution of the nanowires (Fig. 2c), statistical analysis of available spacing between nanowires was done randomly at lower and upper regions. A decreasing trend in spacing between nanowires was observed as ALD cycle numbers increased for spacing in the range of 15.9 nm to 34.9 nm and 43.5 nm to 60.9 nm, at the lower and upper regions, respectively (Fig. 3d). Increasing the number of ALD cycles resulted in the increase in nanowire diameter with a drop in aspect ratio, and eventually reduced the spacing volume between the nanowires.

**Influence of SiO₂ coating thickness on the capture efficiency of ssDNAs**

Since finding the optimum number of ALD cycles is crucial to ensure conformal coating of film layer on the whole nanowire framework, we further investigated the impact of the number of

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**Fig. 2** Characterizations of metal oxide nanowires. (a) STEM micrographs of ZnO/SiO₂ nanowires fabricated with varying number of ALD cycles: 10, 25, 55, 100 and 200 cycles. (b) Plot of the SiO₂ thickness as a function number of ALD cycles. (c) FESEM images of ZnO/SiO₂ nanowires fabricated with 10 cycles, 25 cycles and 55 ALD cycles: (upper row) top and (lower) cross-sectional views.
ALD cycles on the capture efficiency of ssDNAs. We observed that ZnO/SiO$_2$ (core/shell) nanowires fabricated by 10 ALD cycles showed slight improvement of the capture efficiency (Fig. 4a and ESI Fig. 2†). The increasing trend of the capture efficiency could be observed from 0 to 55 cycles followed by a declining trend until 200 cycles. The zeta potential of ZnO/SiO$_2$ nanowires while changing the number of ALD cycles was measured in neutral pH to investigate the net surface charges which might be correlated to the changes in capture efficiency (Fig. 4b). Negative zeta potential values indicate the presence of SiO$_2$ layers which are negatively charged in neutral pH. The high zeta potential value exhibited at 10 cycles (−16.19 mV) was possibly due to a thin SiO$_2$ layer coating that led to interference of charges from the core ZnO nanowires. A consistent trend in zeta potential values, from −24.7 mV to −26.0 mV was observed for nanowires fabricated by 25 ALD cycles to 200 cycles (Fig. 4b) leading to remarkable changes in the capture efficiency (Fig. 3a). Therefore, we concluded the sufficient coating is crucial to ensure the tuning of surface properties to the desired materials.

Further increases in the ALD cycle numbers will cause structural changes to the nanowires and eventually reduce the spacing between the nanowires. Although a higher number of ALD cycles resulted in a bigger nanowire size (Fig. 3b), however, we observed a decline in the capture efficiency from 55 cycles (Fig. 4a) onwards possibly due to a more significant decrease in aspect ratio at 100 and 200 cycles (Fig. 3c), hence the interaction areas, which are the surface of nanowires available for capturing the ssDNAs, were limited. Besides, the low aspect ratio is correlated with the increase in the diameter of nanowires resulting in smaller spacing between nanowires. Considering that the gyration radius of the ssDNA is $R_g < 10$ nm, there should be suitable spacing between the nanowires as interactions are more likely to occur among the nanowires on the periphery of the array as the ssDNAs traverse through the framework. We supposed that the capture efficiency of the ssDNAs was governed by the spacing between nanowires (Fig. 3d) which decreased with increasing ALD cycle numbers.

Here, we proposed a model for capturing ssDNAs based on the structural effect while varying ALD cycle numbers [Fig. 4c]. Apart from the interactions between SiO$_2$ and the nucleobase side, interactions are possible with the phosphate side based on the theory of hard and soft acids and bases although the surface of ssDNA and SiO$_2$ are negatively charged. This is corresponding with previous method, which reported on the DNA adsorption on several metal oxide nanoparticles with negative

![Fig. 3 Statistical analysis of fabricated nanowires. (a) Size distribution of bare ZnO nanowires. (b) Diameter and length. (c) Aspect ratio. (d) Spacing between nanowires.](image)
charged surface.\textsuperscript{45,46} Low capture efficiency at 10 cycles (64.3\%) and 25 cycles (69.0\%) was possibly due to an unsatisfactory trapping region allowing some of the ssDNAs to traverse through the nanowires without being captured. The highest capture efficiency was achieved at 55 cycles (86.7\%) due to the sufficient optimal spacing as a sieving region. Further increase in ALD cycle number from 100 cycles (78.3\%) to 200 cycles (73.2\%) resulted in a decline in the capture efficiency due to small spacing for capturing ssDNAs, hence the capture might be inhibited and occurring only at the top of the nanowires. We hypothesized that the design of the nanowire framework with an optimum trapping region will promote capturing as the ssDNAs traverse through the nanowire arrays, hence ensuring high capture efficiency.

**Conclusion**

In this research, we proved surface modification by coating a thin SiO$_2$ layer on ZnO nanowires using ALD was able to enhance the capture efficiency of ssDNAs. In order to obtain the maximum capture efficiency, finding the optimum number of ALD cycles is crucial to ensure adequate coating of the whole nanowire framework with the desired materials and to provide a suitable trapping region to capture the ssDNAs. We proposed that in the design of the framework, an optimum spacing between nanowires is crucial to ensure a suitable trapping region as the ssDNAs traverse through the nanowires. Besides, by using the optimum condition, higher capture efficiency (86.7\%) was achieved compared to our previously reported study (60\%).\textsuperscript{47} This research provides fundamental findings based on the design of the core/shell nanowire framework in microfluidic devices which will be useful in future development of applications for high capture efficiency of ssDNAs.

**Author contributions**

M. M., T. Yasui, N. K., T. Yanagida and Y. B. planned and designed the experiment. M. M. and N. K. performed the

Conflicts of interest

There are no conflicts to declare.

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